SYNTH ONE POT The Use of Diazonium Salts under Safer Conditions Programme JCJC 2010



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Aryl diazonium salts are a class of super-electrophile with the common structure of R-N₂X. The high nucleofugic properties of the diazonium function makes these compounds potentially hazardous, especially on large scale. As the stability cannot be anticipated, safety issues need to be addressed.





The Heck-Mizoroki reaction has become a standard in the toolbox of every synthetic chemist. A far less explored variant of this coupling, known as the Heck-Matsuda reaction,^[1] entails the use of aryl diazonium salts. The super-electrophile properties of aryl diazonium salts allows the reaction to proceed under mild conditions (T < 60° C), without the need of ligand, and even sometimes, base,^[2] featuring many advantages, for the development of sustainable processes.

2 – Traditionnal Diazonium Salts Preparation

Aryl diazonium salts are commonly prepared from the corresponding aniline, by action of an alkyl nitrite or the sodium nitrite in the presence of a protic acid such as HCI or HBF_4 (H-X).

3 - Catalytic Cycle

Palladium intermediates bear a positive charge during the catalytic cycle. This uncommon feature renders very active the intermediates **C**, **D** and **F**, and optional the use of a base. In the absence of a base, one molar equivalent of a non trapped acid (H-X) is generated per equivalent of olefin **G** formed.



With many substrates we observed the beneficial effect of an additive. A rapid screening concluded that anisole was the privilegied additive.

Triethylsilane 54 *Anisóle 97* Thioanisole 10



reaction scope Ihe showed that the protocol was compatible with a function of variety including ester, nitro, ether, etc. We, however, observed that ortho substituted anilines give consistantly higher yields of coupling products. In order to understand this unexpected behavior, we DFT conducted calculations.^[4]

6 – Theoritical calculations at B3LYP/SDD+f (pd atom), 6-31G** (other atoms) level

We theoretically compared four reactions pathways in order to evaluate the impact of both the substituent position (*para vs. ortho*) and the additive on the reaction outcome. As depicted in the diagram, the product issued from the oxidative addition step (compound **B**) is favoured with *ortho*-substituted compounds (black full line). However, with *para*-substituted substrates, the use of anisole allows a good stabilization of intermediate **B** and avoids the formation of by-products (grey full line). In the absence of anisole, the destabilization of **B** leads to concurrent side-reactions that decrease the reaction yields (black and grey dashed lines). The beneficial effect of anisole has been confirmed with NBO analysis where a stabilizing interaction (Δ Estab~ 47.3 kcal/mol) has been found between the methoxy group of anisole and the palladium atom



> With these observations in mind, we anticipated that a catalytic amount of the acid, H-X, could be used in a **cascade diazonium formation - Heck coupling process**, according to the following unprecedented double catalytic cycle.^[3]

- ➢Only 0.2 equivalent of an non corrosive organic acid !
- Diazonium salts is generated in situ through the reaction advancement !
 - Strategy with an unprecedented double catalytic cycle !
 - The first use of a catalytic amount of diazonium salts !

> Only *t*-BuOH, H_2O and N_2 are generated as by-products !





An acid screening showed that sulfonic acids were much more effective !

First Heck-Matsuda reaction using a substoichiometric amount of diazonium !

 \succ Mild conditions, and only environmentally benign byproduct such as *t*-BuOH, H₂O, and N₂!

No isolation of hazardous aryl diazonium salts !

8 – References

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